Your	Name:					

3.225 Quiz 2007

 $\begin{array}{l} e{=}1.602x10^{-19}~C\\ m_o{=}9.11x10^{-31}~kg\\ c{=}2.998x10^8~m/sec\\ \epsilon_o{=}8.854x10^{-12}~F/m\\ k_b{=}1.38x10^{-23}~J/K\\ h{=}6.626x10^{-34}~J{-}sec\\ h{=}1.054x10^{-34}~J{-}sec\\ A{=}6.022x10^{23}~mole^{-1}\\ \end{array}$

1. 1-D Silicon

Silicon has a valence 4, a=0.5428nm

(a) Using the Drude model, calculate the estimated conductivity along the 1-D wire

$$n = \frac{Z}{a} = \frac{4}{a}, \sigma = \frac{ne^2\tau}{m_0} \rightarrow \text{calculate using } \tau = 10^{-14} \text{s}$$

(b) What is the plasma frequency?

$$\omega_{\rm p} = \sqrt{\frac{{\rm ne}^2}{{\rm m}_0 \varepsilon_0}}$$

c) Now let us have electron waves instead of electron particles in our 1-D Si; determine k_{F} and E_{F}

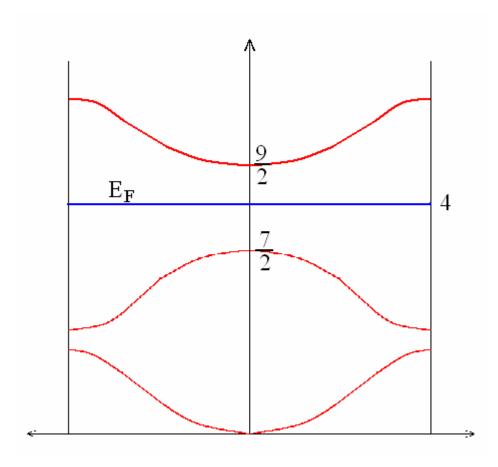
$$k_F^{1-d} = \frac{n\pi}{2}, n = \frac{4}{a} \Rightarrow k_F^{1-d} = \frac{2\pi}{a}$$

$$E_F^{1-d} = \frac{\hbar^2 k_F^2}{2m} = \frac{2\pi^2 \hbar^2}{m^* a^2}$$

(d) Derive the density of states for the 1-D Si for free electron waves

$$\begin{split} g\left(E\right)^{\text{1-d}} = & \frac{dN}{dk} \frac{dk}{dE} \frac{1}{L}, \, N = \frac{2kL}{\pi}, \, k = \frac{\sqrt{2mE}}{\hbar} \\ \Rightarrow & g\left(E\right)^{\text{1-d}} = \frac{\sqrt{2m}}{\pi\hbar} \frac{1}{\sqrt{E}} \end{split}$$

(e) If the band gap of interest is $(\hbar^2\pi^2/(2m_0a^2))$, draw the E vs. band structure for nearly free electron silicon



2. 2-D Semiconductor

(a) Derive the density of states for a 2-D semiconductor, $g(E)=m^*/(\pi\hbar^2)$

$$\begin{split} g\left(E\right)^{2\text{-d}} &= \frac{dN}{dk} \frac{dk}{dE} \frac{1}{L}, \, N = \frac{k^2 L^2}{2\pi}, \, k = \frac{\sqrt{2m^*E}}{\hbar} \\ \Rightarrow g\left(E\right)^{2\text{-d}} &= \frac{m^*}{\pi \hbar^2} \end{split}$$

(b) Assume that $E_g = 1.1 \, eV$ for this intrinsic 2-D semiconductor (i.e. same as for 3-D Si). Calculate n at room temperature and compare to 3-D Si, where $n = 10^{10} \, cm^{-3}$ for intrinsic material. Assume m*=m₀.

Number of e⁻per area in conduction band = n (as 2-d semi conductor)

$$\begin{split} n &= \int\limits_{E_C}^{\infty} f\left(E\right) g^{2\text{-d}}\left(E\right) \! dE, \, f\left(E\right) \sim \, exp\left(-\frac{E\text{-}E_F}{k_b T}\right), \, \, E_F = \frac{E_g}{2} \, \text{ and } E_C = E_g \, \left(\text{as intrinsic}\right) \\ g^{2\text{-d}}\left(E\right) &= \, \frac{m^*}{\pi \hbar}, \, \, \Rightarrow \, n = \int\limits_{E_C}^{\infty} f\left(E\right) g^{2\text{-d}}\left(E\right) \! dE = \frac{m^*}{\pi \hbar} \int\limits_{E_g}^{\infty} exp\!\left(-\frac{E}{k_b T} + \frac{E_g}{2k_b T}\right) dE \\ \Rightarrow \, n &= \, \frac{m^* k_b T}{\pi \hbar} \, exp\left(-\frac{E_g}{2k_b T}\right) \end{split}$$

 $n^{2-d} \le n^{3-d}$ as unlike $g^{3-d}(E)$, $g^{2-d}(E)$ is not an increasing function of E (in fact it is a constant).

3. Dielectric Properties

Describe $\varepsilon(\omega)$ for 1-D Si in the context of the sources of polarization.

Just electronic polarization...draw $\varepsilon(\omega)$ vs ω . Show ω_{oe} etc.